



In-situ Oxygen-driven Growth Regulation and Defect Passivation in Chemical Vapor Deposited MoS₂ Monolayers

Presented by Santhosh Durairaj

2D Materials Laboratory, Department of Physics and Nanotechnology, SRM Institute of Science and Technology, Kattankulathur 603 203, Tamil Nadu, India









(a) Schematic diagram of the experimental setup used growth of MoS_2 (b) photograph of the grown MoS_2 on sapphire substrate (c,d) Optical microscope and HRSEM image of MoS_2





(a) Raman spectra of sample A (SiO2 support), sample B (quartz support) and sample C (Gas phase) CVD (b) μ -PL spectra of sample A, B and C (c,d) PL intensity maps of sample A and B





HRTEM analysis of the grown MoS₂ films. Figure (a) shows the raw image and (b) and (c) are the inverse FFT images of sample A. The raw and inverse FFT images of sample B are

shown in (d) and (e-f), respectively.



Temperature-dependent μ -PL spectra of MoS₂ for (a) sample A and (b) sample B. (c) Comparison of the PL spectrum recorded at 93 K. (d) Variation in the A exciton energy with temperature. The solid lines are Varshni fit to the experimental data.



-2.5 nm

3.0 µm

2.<u>5 n</u>m

 2 nm

 2 nm

 -2 nm

 Height
 1.0 μm



Sample B







(a-d) Raman and µ-PL spectra of MoS₂ samples before and after post sulfurization

2.0

2.1

2.2

1.9

Energy (eV)

1.6

1.7

1.8

1.9

Energy (eV)

2.0

2.1

2.2

0.0

1.7

1.8



- □ An effective method for passivating the V_S *in situ* by using an oxide substrate in the vapor phase CVD
- □ The chemisorbed oxygen is found to have a strong impact on the defect sites such that it transforms the localized trap states to electronically benevolent sites, which exhibited very strong band edge photoluminescence
- □ In the absence of oxygen, the growth of MoS_2 and its structure is greatly altered. The present findings also provided new insights into the phonon behavior in highly defective monolayer MoS_2

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